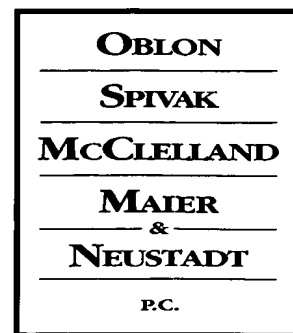




Docket No.: 0039-7632-0X

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313



ATTORNEYS AT LAW

RE: Application Serial No.: 09/531,163

Applicants: Masayuki HATTORI, et al.

Filing Date: March 17, 2000

For: AQUEOUS DISPERSION, AQUEOUS DISPERION  
FOR CHEMICAL MECHANICAL POLISHING USED  
FOR MANUFACTURE OF SEMICONDUCTOR  
DEVICES, METHOD FOR MANUFACTURE OF  
SEMICONDUCTOR DEVICES, AND METHOD FOR  
FORMATION OF EMBEDDED WIRING

Group Art Unit: 1765

Examiner: DEO, DUY VU NGUYEN

SIR:

Attached hereto for filing are the following papers:

**Request for Extension of Time (1 month)  
Notice of Appeal**

Our check in the amount of \$440.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.

Norman F. Oblon

Registration No. 24,618

Customer Number

**22850**

(703) 413-3000 (phone)  
(703) 413-2220 (fax)

Stefan U. Koschmieder, Ph.D.  
Registration No. 50,238